



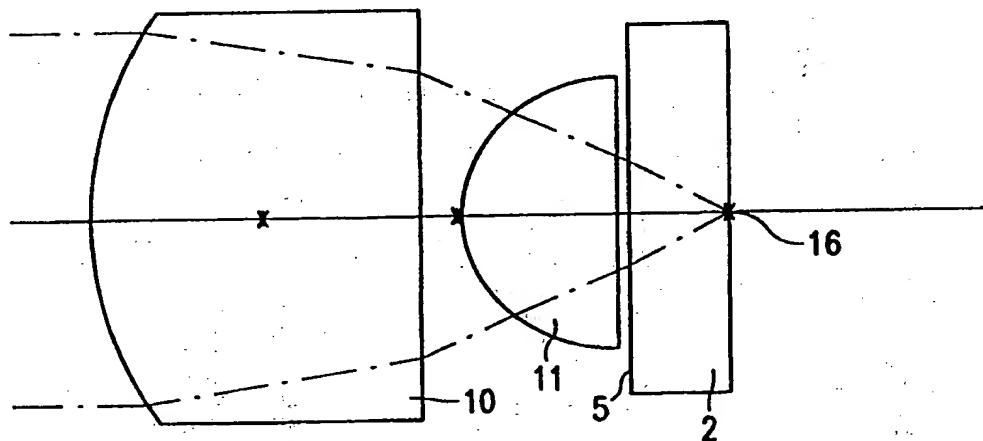
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(71) Applicant: KONINKLIJKE PHILIPS ELECTRONICS N.V. [NL/NL]; Groenewoudseweg 1, NL-5621 BA Eindhoven (NL).			
(71) Applicant (for SE only): PHILIPS AB [SE/SE]; Kottbygatan 7, Kista, S-164 85 Stockholm (SE).			
(72) Inventor: BRAAT, Josephus, Johannes, Maria; Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL).			
(74) Agent: VISSER, Derk; Internationaal Octrooibureau B.V., P.O. Box 220, NL-5600 AE Eindhoven (NL).			

(54) Title: DEVICE FOR OPTICALLY SCANNING A RECORD CARRIER

(57) Abstract

A device is described for optically scanning a record carrier with a radiation beam having a high numerical aperture. The radiation beam is focused on the record carrier by means of an objective lens and a plano-convex lens. The plano-convex lens has a gap with the record carrier of several tens of micrometers. It focuses the radiation beam to a point at least 30 focal depths away from an aplanatic point of the plano-convex lens. As a consequence, the lens has a relatively large tolerance for sideways movements.



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Device for optically scanning a record carrier.

The invention relates to an optical scanning device for optically scanning a record carrier comprising an information plane and a transparent layer, the device comprising an objective lens and a plano-convex lens for converging a radiation beam through the transparent layer to a focus on the information layer, the plano-convex lens having a convex surface facing the objective lens, and a planar surface facing the transparent layer.

The amount of information that can be stored on an optical record carrier depends inter alia on the size of the radiation spot formed by the scanning device on the information layer of the record carrier. The information density and hence the amount of stored information can be increased by decreasing the size of the spot. The spot size can be reduced by increasing the numerical aperture of the radiation beam forming the spot. When using a single objective lens, such an increase of the numerical aperture is in general accompanied by a decrease of the free working distance of the lens forming the radiation beam, i.e. the smallest distance between the record and the lens. At higher numerical apertures, the manufacturing costs of such objective lenses become high, the field of the lens reduces and the dispersion of the material the lens is made of gives increasing problems. The problems may be mitigated by inserting a plano-convex lens between the objective lens and the record carrier. The plano-convex lens, sometimes called a slider lens or a solid immersion lens, is arranged at a very small distance above the record carrier. The convergence of the radiation beam is then distributed over the objective lens and the plano-convex lens. An advantage of the use of the plano-convex lens is that it hardly adds aberrations to the radiation beam.

A scanning device having such a plano-convex lens is known from the European patent application no. 0 727 777. The device comprises an optical head in which an objective lens and a plano-convex lens converge a radiation beam to a numerical aperture (NA) of 0.84 for scanning the record carrier. The plano-convex lens is arranged at a small height above the record carrier. The lens may be mounted on a slider in sliding contact with the record carrier or floating on a thin air layer. The lens has a free working distance of several micrometers. When the optical head of the device, flying above the surface of the record carrier, collides with a dust particle on the surface, the head and record carrier will

be damaged. The free working distance should therefore be larger than the size of the contamination expected on the record carrier. A disadvantage of the known device is that the manufacture of the optical head of the device becomes increasingly difficult at increasing free working distance.

5 It is an object of the invention to provide a scanning device for scanning a record carrier with a high numerical aperture radiation beam, which can be easily manufactured.

The object is achieved in accordance with the invention by a scanning device as described in the opening paragraph, which is characterized in that the objective
10 lens and plano-convex lens are designed for forming a focus at a distance of more than thirty focal depths of the converging radiation beam from an aplanatic point of the plano-convex lens.

It has turned out that the difficult manufacture of the known optical head is due to the tight tolerance on sideways displacements of the plano-convex lens relative to
15 the position of the objective lens. The gap between the flat surface of the plano-convex lens and the record carrier introduces spherical aberration in the radiation beam which is focused on the record carrier. The spherical aberration can be compensated in the objective lens. As a result, an aberrated beam enters the plano-convex lens instead of an unaberrated beam. This aberration makes the centring of the objective lens and the known plano-convex lens in
20 a direction perpendicular to the optical axis of the lenses critical. The centring tolerance becomes more tight with increasing free working distance. The objective lens and the plano-convex lens are preferably separately movable along their optical axes for a proper tracking of the record carrier. The tight positional tolerance on the known plano-convex lens and the objective lens makes the actuators for these movements expensive.

25 The tight tolerance of the known optical head is a consequence of the design of the optical head. In applications where plano-convex lenses are used for forming a high numerical aperture beam, such as high-magnification microscope objective lenses and optical heads for scanning high-density optical record carriers, the radiation beam is always focused in an aplanatic point of the plano-convex lens, because only then the plano-convex
30 lens increases the numerical aperture of the beam without introducing monochromatic aberrations. See for example the book "Principles of Optics" by M. Born and E. Wolf, sixth edition, Pergamon Press, 1980, page 253.

The tolerance of the optical head according to the invention is substantially larger than that of the known optical head because of the different design of the

objective lens and the plano-convex lens. The inventive design does not focus the radiation beam at an aplanatic point of the plano-convex lens, but at a point which does not coincide with such an aplanatic point. The relatively small increase of the aberrations introduced by the plano-convex lens according to the invention is accompanied by a relatively large increase in the tolerance for sideways movements of the lens. When the distance between the focus point and an aplanatic point is more than thirty focal depths of the radiation beam away from an aplanatic point, the increased tolerance substantially simplifies the manufacture of the optical head. A focal depth is equal to $\lambda/(4(1 - \cos \alpha))$, where λ is the wavelength of the radiation beam and α is the half-angle of the cone of the converging beam in air. The focal depth of a converging beam having a half-angle of α in a medium having a refractive index n is approximately n times larger than in air. The numerical aperture NA is equal to $(n \sin \alpha)$. When the free working distance is increased to a few tens of micrometers, where dust particles can pass between the lens and the record carrier, the tolerance is relatively large. For gaps larger than $50 \mu\text{m}$, the distance between the focus point and an aplanatic point is preferably larger than one hundred focal depths.

To increase the tolerance for thickness variations of the transparent layer of the record carrier, the refractive index n_1 of the transparent layer is preferably larger than the refractive index n_2 of the plano-convex lens.

The spherical aberration caused by the gap between the plano-convex lens, having a refractive index lower than n_2 , and the transparent layer, having a refractive index larger than n_2 , at least partly compensate one another. The amount of spherical aberration to be introduced by the objective lens is then reduced, which in turn further increases the mentioned positional tolerance. The refractive indices are preferably related through $(n_1 - 1) > 1.03 (n_2 - 1)$.

The distance between the focus and an aplanatic point depends in general on the size of the gap between the plano-convex lens and the record carrier. The preferred distance measured in micrometers is substantially equal to $3Rd_{\text{gap}}$, where R is the radius of the convex surface in millimetres and d_{gap} the distance between the planar surface and the transparent layer in micrometers. The distance depends on the actual design of the objective lens and the plano-convex lens. The distance will in general lie within +150% to -50% from the above value, and, if $n_1 > n_2$, within $\pm 20\%$ of the above value. The focus is preferably arranged between the two aplanatic points of the plano-convex lens.

To obtain a minimum spherical aberration at the location of the focus, the size of the gap, d_{gap} , depends preferably on the refractive index n_2 of the plano-convex lens

and n_1 of the transparent substrate according to the following relation:
 $d_{\text{gap}}/d_s = (n_2/n_1^3) * (n_1^2 - n_2^2) / (n_2^2 - 1)$. The value of d_{gap} preferably complies with the relation within 40% for values of d_s larger than d_{gap} , where d_s is the thickness of the transparent layer. The value of d_s is preferably larger than the value of d_{gap} in order to obtain refractive indices of available materials.

The plano-convex lens according to the invention is designed for a magnification different from that of the known plano-convex lens. The known lens has a magnification of $1/n_2$, where n_2 is the refractive index of both the lens body and the transparent layer. The known lens therefore operates in an aplanatic point and complies with the sine condition. The plano-convex lens according to the invention operates preferably at a magnification of between $1.1/n_2^2$ and $0.99/n_2$, and more preferably within a range between $0.7/n_2$ and $0.99/n_2$. In this range the amount of spherical aberration compensated in the objective lens is smaller than for an objective lens in the known device which has a similar size of the gap. This change from the known design makes the plano-convex lens more tolerant to sideways movements at a large free working distance. When, additionally, the refractive index n_1 of the transparent layer is chosen larger than the refractive index n_2 of the plano-convex lens, the tolerance for sideways movements is further increased and the tolerance for thickness variations of the transparent layer is increased.

The objects, advantages and features of the invention will be apparent from the following more particular description of preferred embodiments of the invention, as illustrated in the accompanying drawings.

Figure 1 shows a scanning device and

Figure 2 shows an objective lens and a plano-convex lens.

Figure 1 shows a device for scanning an optical record carrier 1. The record carrier comprises a transparent layer 2, on one side of which an information layer 3 is arranged. The side of the information layer facing away from the transparent layer is protected from environmental influences by a protection layer 4. The side of the transparent layer facing the device is called the entrance face 5. The transparent layer 2 acts as a substrate for the record carrier by providing mechanical support for the information layer. Alternatively, the transparent layer may have the sole function of protecting the information layer, while the mechanical support is provided by a layer on the other side of the

information layer, for instance by the protection layer 4 or by a further information layer and transparent layer connected to the information layer 3. Information may be stored in the information layer 3 of the record carrier in the form of optically detectable marks arranged in substantially parallel, concentric or spiral tracks, not indicated in the Figure. The marks
5 may be in any optically readable form, e.g. in the form of pits, or areas with a reflection coefficient or a direction of magnetization different from their surroundings, or a combination of these forms.

The scanning device comprises a radiation source 6, for example a semiconductor laser, emitting a diverging radiation beam 7. A beam splitter 8, for example a
10 semi-transparent plate, reflects the radiation towards a lens system. The lens system comprises a collimator lens 9, an objective lens 10 and a plano-convex lens 11. The collimator lens 9 changes the diverging radiation beam 7 to a collimated beam 12. The objective lens 10, having an optical axis 13, transforms the collimated radiation beam 12 into a converging beam 14 incident on the lens 11. The collimator lens 9 and the objective lens
15 10 may be combined into a single lens. The plano-convex lens 11 changes the incident beam 14 into a converging beam 15, which comes to a focus 16 on the information layer 3. The plano-convex lens 11 has a convex surface and a flat surface. The flat surface faces the transparent layer 2 and forms a gap between the lens and the layer. Although the objective lens 10 is indicated in the Figure as a single lens element, it may comprise more elements,
20 and may also comprise a hologram operating in transmission or reflection, or a grating for coupling radiation out of a waveguide carrying the radiation beam. Radiation of the converging beam 15 reflected by the information layer 3 forms a reflected beam 17, which returns on the optical path of the forward converging beam 14. The objective lens 10 and the collimator lens 9 transform the reflected beam 17 to a converging reflected beam 18, and the
25 beam splitter 8 separates the forward and reflected beams by transmitting at least part of the reflected beam 18 towards a detection system 19. The detection system captures the radiation and converts it into one or more electrical signals. One of these signals is an information signal 20, the value of which represents the information read from the information layer 3. Another signal is a focus error signal 21, the value of which represents the axial difference
30 in height between the focus 16 and the information layer 3. The focus error signal is used as input for a focus servo controller 22, which controls the axial position of the objective lens 10 and/or the plano-convex lens 11, thereby controlling the axial position of the focus 16 such that it coincides substantially with the plane of the information layer 3. The part of the detection system, including one or more radiation-sensitive detection elements and an

electronic circuit processing the output signal of the detection elements, used for generating the focus error is called the focus error detection system. The focus servo system for positioning the lens system comprises the focus error detection system, the focus servo controller and an actuator for moving the lens system.

5 The gap, i.e. the distance between the planar surface of lens 11 and the entrance surface 5 of the record carrier 1, should be maintained substantially at a nominal value. This can be attained by using a passive air bearing construction carrying lens 11 and designed to maintain the gap at its nominal value. It is also possible to use an optically derived error signal which represents the deviation of size of the actual gap from its nominal
10 value; a special actuator then keeps the plano-convex lens at its prescribed distance from the transparent layer by using the error signal as an input signal for the actuator servo loop. The actuator of the lens 10 is controlled by the focus error signal 21 to keep the focus 16 on the information layer 3.

 The spherical aberration which arises when the radiation beam has to be
15 focused through a transparent layer which is thicker than the design thickness of the layer, is compensated for by a focusing action of the objective lens. The focusing action causes the plano-convex lens to produce, due to the changing magnification, an amount of spherical aberration which cancels the aberration produced by the thicker transparent layer. During the focusing action of the objective lens, the gap should be maintained substantially at its
20 nominal value in the above-mentioned way.

 Figure 2 shows an enlargement of the objective lens 10 and the plano-convex lens 11. The objective lens 10 may be a mono-aspherical plano-convex lens or a bi-aspherical lens. The objective lens 10 is designed in a known way to compensate for the spherical aberration introduced by the plano-convex lens 11 and the transparent layer 2,
25 thereby making the radiation beam near the focus 16 nominally substantially free from spherical aberration.

 Table I shows design parameters of the plano-convex lens 11. Designs no. 1 and 5 are according to the prior art, whereas designs 2-4 and 6-7 are according to the invention. The parameters in the table have the following meaning: d_{gap} is the distance
30 between the flat surface of the plano-convex lens 11 and the entrance face 5 of the transparent layer 2; R is the radius of the convex surface of the plano-convex lens; n_2 is the refractive index of the lens material; Δs is the distance between the focus point and the aplanatic point corresponding to a magnification of $1/n_2$. Δs is measured in the direction of the aplanatic point corresponding to a magnification of $1/n_2^2$ and in a medium having a

refractive index of n_2 . B is the magnification of the plano-convex lens in units of $1/n_2$. F is the root-mean-square (RMS) wavefront error close to the focal point at a distance of $30\text{ }\mu\text{m}$ in the field of the lens. D is the RMS wavefront error for a sideways displacement of the plano-convex lens of $30\text{ }\mu\text{m}$. T is the RMS wavefront error when the thickness of the transparent layer 2 is $30\text{ }\mu\text{m}$ less than the design thickness.

The wavelength of the radiation is 650 nm and the NA of the converging beam 15 is 0.85 in air. The focal depth is equal to $0.343\text{ }\mu\text{m}$. The design thickness of the transparent layer 2 is identical for the designs 1-7 and is equal to $600\text{ }\mu\text{m}$. The refractive index of the layer is 1.5806 , i.e. the refractive index of polycarbonate (PC) at a wavelength of 650 nm . The plano-convex lens 11 of the designs 1-3, 5 and 6 is made of polycarbonate. The plano-convex lens of the design 4 and 7 is made of the glasses BK10 and K5 respectively from the Schott catalog. The axial thickness of the plano-convex lens is defined by the gap thickness, the thickness of the transparent layer, the radius of curvature and the magnification of the plano-convex lens.

No.	$d_{\text{gap}}(\mu\text{m})$	R (mm)	n_2	$\Delta s(\mu\text{m})$	B ($1/n_2$)	F (m λ)	D (m λ)	T (m λ)
1	50	1.2492	1.5806	0	1.000	24	61	57
2	50	1.2492	1.5806	30	0.989	24	55	51
3	50	1.2492	1.5806	295	0.863	31	20	47
4	50	1.2492	1.4901	197	0.923	25	16	10
5	25	1.2350	1.5806	0	1.000	21	33	29
6	25	1.2350	1.5806	216	0.900	14	15	17
7	25	1.2350	1.5238	92	0.961	20	13	15

Table 1 Design parameters of plano-convex lens

Design no. 1 in the table shows the parameters of a plano-convex lens according to prior art design rules for a gap of $50\text{ }\mu\text{m}$. The refractive index of the lens material is equal to the refractive index of the transparent layer 2, and the focus point coincides with the aplanatic point corresponding to a magnification of $1/n_2$.

Design no. 2 according to the invention uses the same refractive index as that

of PC, but has a focus of the beam at a distance of $30\text{ }\mu\text{m}$ from the aplanatic point. This distance corresponds to 87 focal depths. The RMS wavefront error at $30\text{ }\mu\text{m}$ decentring reduces from 61 to 55 m λ . If the scanning device imposes a tolerance of $30\text{ }\mu\text{m}$ on the decentring, the 10% reduction of the accompanying wavefront error can be used

5 advantageously in reducing other tolerances in the often tight optical wavefront error budget of the scanning device. Since the wavefront error is to a first approximation linear in the decentring, design no. 2 allows a 10% larger tolerance on the decentring of the plano-convex lens. The tolerance on thickness variations of the transparent layer has also increased by more than 10%.

10 Design no. 3 uses again the refractive index of PC but has a focus at a distance of $295\text{ }\mu\text{m}$ from the aplanatic point. The tolerance on the decentring has been increased by a factor of three at the cost of a slight reduction of the field of the lens. The tolerance on the layer thickness has also increased.

Design no. 4 uses a refractive index lower than that of the transparent layer
15 and has a focus $197\text{ }\mu\text{m}$ away from the aplanatic point. The field of the lens is about equal to the field of the lens according to the prior art design no. 1. The decentring tolerance has been decreased even further than in design no.3 and the thickness tolerance has increased by more than a factor of five in comparison with design no. 1.

Design no. 5 shows the parameters of a plano-convex lens according to prior
20 art design rules for a gap of $25\text{ }\mu\text{m}$. The refractive index of the lens material is equal to the refractive index of PC, and the focus point coincides with the aplanatic point corresponding to a magnification of $1/n_2$.

Design no. 6 according to the invention uses the refractive index of PC but has
a focus at a distance of $216\text{ }\mu\text{m}$ from the aplanatic point. Both the field of the lens, the
25 tolerance on the decentring, as well as the tolerance on the layer thickness have increased by about a factor of two.

Design no. 7 uses a refractive index lower than that of the transparent layer
and has a focus $92\text{ }\mu\text{m}$ away from the aplanatic point. The field is still larger than the field
of design no. 5. The decentring tolerance has increased even further than in design no. 6.
30 The thickness tolerance has increased fourfold in comparison with design no. 5. When the optical budget of the scanning device for sideways movements is 30 m λ , the plano-convex lens according to design no. 5 has a $27\text{ }\mu\text{m}$ tolerance for sideways movements, whereas the plano-convex lens according to design no. 7 has a $69\text{ }\mu\text{m}$ tolerance.

CLAIMS:

1. An optical scanning device for optically scanning a record carrier comprising an information plane and a transparent layer, the device comprising an objective lens and a plano-convex lens for converging a radiation beam through the transparent layer to a focus on the information layer, the plano-convex lens having a convex surface facing the objective lens, and a planar surface facing the transparent layer, characterized in that the objective lens and plano-convex lens are designed for forming a focus at a distance of more than thirty focal depths of the converging radiation beam from an aplanatic point of the plano-convex lens.
2. Optical scanning device according to Claim 1, wherein the transparent layer and the plano-convex lens have refractive indices n_1 and n_2 respectively, the value of n_1 being larger than the value of n_2 .
3. Optical scanning device according to Claim 2, wherein the refractive indices n_1 and n_2 are related through $(n_1-1) > 1.03 (n_2-1)$.
4. Optical scanning device according to Claim 1 or 2, wherein the distance between the focus and an aplanatic point measured in micrometers is substantially equal to $3Rd_{\text{gap}}$, where R is the radius of the convex surface in millimetres and d_{gap} the distance between the planar surface and the transparent layer in micrometers.
5. Optical scanning device according to Claim 1, wherein the magnifying power of the plano-convex lens lies within a range from $1.1/n_2^2$ to $0.99/n_2$, n_2 being the refractive index of the plano-convex lens.

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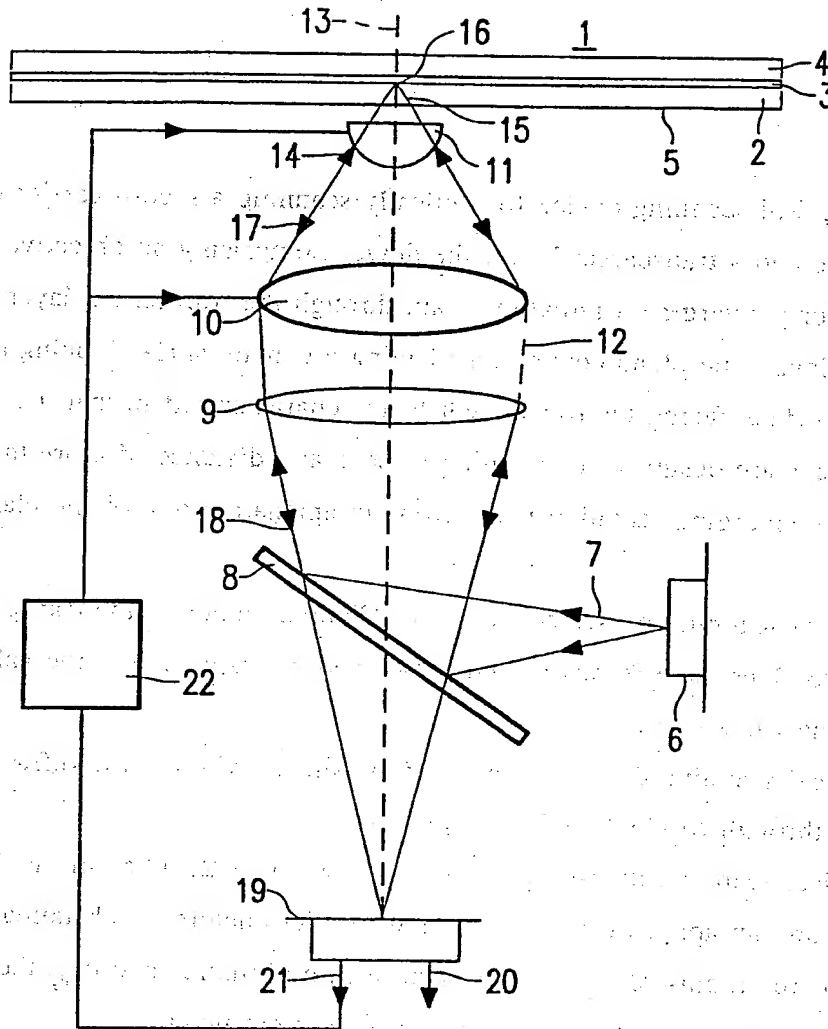


FIG. 1

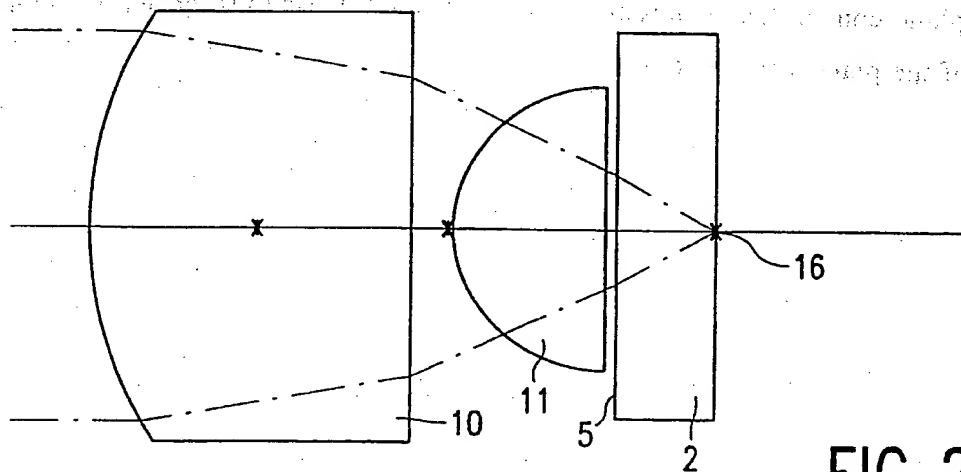


FIG. 2



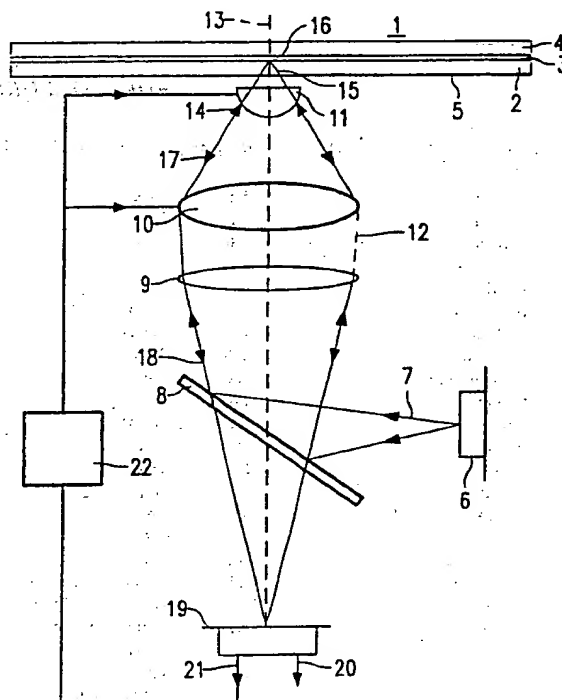
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(54) Title: DEVICE FOR OPTICALLY SCANNING A RECORD CARRIER

(57) Abstract

A device is described for optically scanning a record carrier with a radiation beam having a high numerical aperture. The radiation beam is focused on the record carrier by means of an objective lens and a plano-convex lens. The plano-convex lens has a gap with the record carrier of several tens of micrometers. It focuses the radiation beam to a point at least 30 focal depths away from an aplanatic point of the plano-convex lens. As a consequence, the lens has a relatively large tolerance for sideways movements.





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INTERNATIONAL SEARCH REPORT

International application No.

PCT/IB 98/00674

A. CLASSIFICATION OF SUBJECT MATTER

IPC6: G11B 7/135

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

IPC6: G11B, G02B

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

SE,DK,FI,NO classes as above

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

EPAT, WPI, JAPIO

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	Patent Abstracts of Japan, abstract of JP 8-212579 A (SONY CORP), 20 August 1996 (20.08.96) --	1-5
A	US 5602383 A (TARO TAKEKOSHI ET AL), 11 February 1997 (11.02.97) --	1-5
A	EP 0727777 A1 (SONY CORPORATION), 21 August 1996 (21.08.96) -- -----	1-5

☐ Further documents are listed in the continuation of Box C.

☒ See patent family annex.

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Date of the actual completion of the international search

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Name and mailing address of the ISA/
Swedish Patent Office
Box 5055, S-102 42 STOCKHOLM
Facsimile No. +46 8 666 02 86

Authorized officer

Benny Andersson

Telephone No. +46 8 782 25 00

INTERNATIONAL SEARCH REPORT

Information on patent family members

01/12/98

International application No.

PCT/IB 98/00674

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